

ELECTROLUMINESCENCE OF Er^{3+} -IMPLANTED ZnSe MIS DIODES

Hua TIAN and Xiwu FAN (X.W. Fan)

Changchun Institute of Physics, Academia Sinica, Changchun, China

Shaohong XU

Shanghai University of Science and Technology, Shanghai, China

The ZnSe:Er³⁺ MIS diodes were prepared using Er³⁺-implantation technique at room temperature. The origin of the I layer was investigated, and the green high-field electroluminescence of Er³⁺ was obtained in the forward biased ZnSe:Er³⁺ MIS diodes.

1. INTRODUCTION

ZnS:RE³⁺ and ZnSe:RE³⁺ MS diodes^{1,2,3} have been fabricated by using ion implantation technique, and give high-field electroluminescence of RE³⁺ in reverse bias. In this paper, the ZnSe:Er³⁺ MIS diodes were first prepared by Er-implantation at room temperature. The origin of I layer was investigated, and the green high-field electroluminescence of Er³⁺ was first obtained in the forward biased ZnSe:Er³⁺ MIS diodes.

2. EXPERIMENTAL

ZnSe crystals used in this study were grown by sublimation method in our laboratory. Erbium ions with energy of 100 keV and dose of $1 \times 10^{15}/\text{cm}^2$ were implanted into low resistivity ZnSe crystals at room temperature. Annealing was performed in N₂ atmosphere, after annealing the ZnSe:Er³⁺ diodes were prepared by evaporating Au electrode on the implantation surface and making an ohmic contact on the opposite surface of dice.

The C-V characteristics were measured by M-410 C-V plotter, and the optical DLTS (ODLTS) spectra were measured using a Model NJ-M-DLTS instrument added light pulse of a flash lamp and the EL spectra were measured using a Model 44W grating monochromator with a C31034

photomultiplier.

3. RESULTS AND DISCUSSION

The result of C-V measurement indicates that Er³⁺-implanted ZnSe diodes annealed in N₂ atmosphere have MIS structure. Fig. 1 shows the thickness of the I layer d_1 in the ZnSe:Er³⁺ diodes as a function of annealing temperature T.

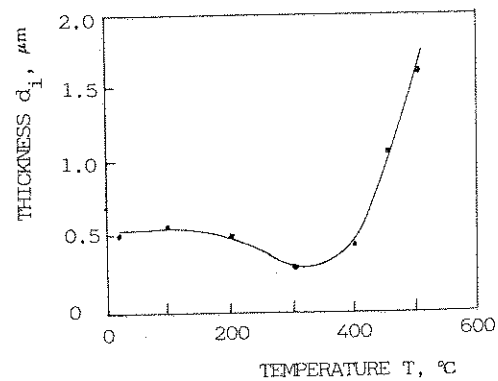
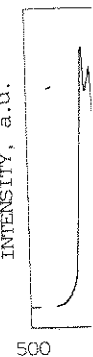


FIGURE 1
Dependence of the thickness of the I layer d_1 on annealing temperature T in ZnSe:Er³⁺ diodes.

Fig. 2 shows the ODLTS spectra of unimplanted ZnSe (a), unannealed ZnSe:Er³⁺ (b) and ZnSe:Er³⁺ annealed at 300 °C (c). It is found that there are two levels, $E_c - 0.42\text{eV}$ and $E_c - 0.72\text{eV}$, in the ZnSe:Er³⁺ diode. The ODLTS



ODLTS spectra



EL spectra diodes.

spectra of wafer at d layer were

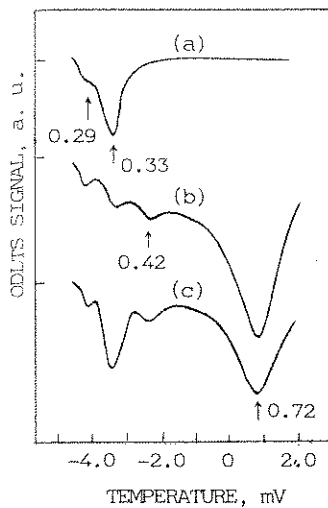


FIGURE 2
 ODLTS spectra in ZnSe crystals.

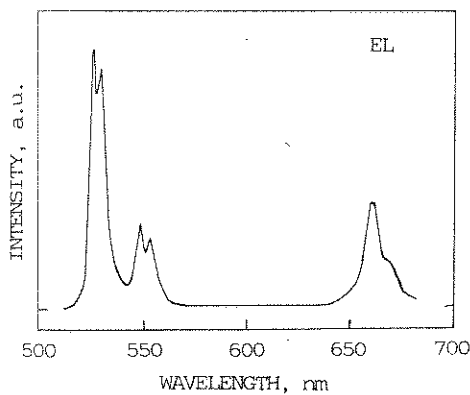


FIGURE 3
 EL spectra in the forward-biased ZnSe:Er³⁺ MIS diodes.

spectra of an unannealed Er³⁺-implanted ZnSe wafer at different etching depth in implanted layer were also measured. It is obvious that

the range of radiation damage is approximately equal to the thickness of the I layer in the diode. From these results it can be concluded that the I layer in the diode is caused by radiation damage.

From the theory of ion implantation⁴, it can be calculated that the projected range of the Er³⁺ ions lie in the I layer of the diodes. Green electroluminescence of Er³⁺ in forward-biased ZnSe:Er³⁺ MIS diodes is obtained, as shown in Fig. 3. Since the dependences of B and I on V of the diodes can be expressed as $B \propto \exp(-b/\sqrt{V})$, $I \propto \exp(-b'/\sqrt{V})$, respectively, and the intensity ratio of 5300 Å line to 6700 Å line increases with increasing the forward voltage, the Er³⁺ ions are excited by hot electron through direct excitation. Thus the luminescent mechanism of the diodes is similar to that of GaN:Zn MIS diodes⁵. Since rare-earth ions are effective luminescent center in high electric field, the luminescent efficiency is likely to be high in this kind of diodes.

This work was supported by the National Natural Science Foundation of China.

REFERENCES

1. G.Z. zhong and F.J. Bryant, Chinese Lumin. and Display Devices 4(3) (1983) 42.
2. G.Z. Zhong and F.J. Bryant, J. Phys. D 15 (1982) 705.
3. Tian Hua, Fan Xiwu and Xu Shaohong, Chinese J. Lumin. 7 (1986) 184.
4. Luo Jinsheng, Physics of Ion Implantation Chapter 2 (1979).
5. J.I. Pankove et al., Phys. Rev. Lett. 33 (1974) 361.

on temperature.
 luminescence of

indicates that
 led in N₂ atmo-
 y. 1 shows the
 the ZnSe:Er³⁺
 ng temperature



T, °C

e I layer d,
 e:Er³⁺ diodes.

ra of unimplan-
 :Er³⁺ (b) and
). It is found
 E_C-0.42eV and
 de. The ODLTS